

Preliminary Test Beam Results on 2nd BNL Production

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Introduction

- Studying AC-LGAD sensors with 500 µm pitch at the FNAL beam test facility
- Performed a beam test in March 2022 focusing on first batch of long strip BNL sensors
 - Previous test beam presentation to eRD112 (link)
 - Paper detailing 2022 beam test results (<u>arxiv.2211.09698</u>)
- Recently concluded another beam test on second batch of long strip BNL sensors and new HPK 500x500 µm² pixels
 - January 4-10th, 2023
- January 2023 beam test measurement goals
 - Confirm previous performance with uniform gain sensors
 - Measure performance with 50 µm width metal electrodes
 - Study impact of 50 µm vs. 20 µm active thickness for 1cm length BNL sensors
 - **Study thickness variation for HPK pixels**



Fermilab 4D-trackers test beam infrastructure

- Permanent setup in FNAL test beam facility (FTBF)
 - Movable: slide in and out of beamline as needed, parasitic use of beam
 - Environmental controls: sensor temperature (-25 C to 20 C), and humidity, monitoring
 - Remote control (stages, HV, LV), logging & reconstruction; $\sigma T \sim 10$ ps time reference (MCP)
 - Cold operation of up to 10 prototypes at the same time
 - DAQ: high bandwidth, high ADC resolution scope 8-channel scope
 - Record 100k events per minute, tracker with \sim 5 µm resolution
- Developed readout boards for the characterization of LGADs
 - Without complicated ASIC and DAQ







Check gain uniformity





- Greatly improved gain uniformity from first BNL large sensor batch compared to second
- Operating voltage lower for new batch of sensors





- Signal amplitude has decreased for new production
- Similar, time and position resolutions

Should be able to build on previous measurements to understand new sensor thickness



Comparing 400 vs. 450 µm metal electrode size



- resolution
- Observe similar signal amplitude, time and position resolution
 - However, did not reach same operating voltage
- Small improvement to 2 strip efficiency 81% vs. 87%
- Still studying differences but overall very similar

• For 1 cm length sensors conjectured that smaller metal would improve 2 strip efficiency and smooth overall position







Studying 20 µm thick sensors

- At what point are you signal to noise limited vs. Landau limited for the time resolution when varying sensor thickness?
 - If Landau limited on time resolution can try thinner sensors
 - Expect ~2/5 smaller signals for 20 μ m compared to 50 μ m sensors $(60 \text{ mV} \rightarrow 24 \text{ mV})$

Results for best performing BNL 1cm length 20 µm

- Observe ~25 mV signals for direct metal hits
 - ~65 mV signals for 50 μm version
- Do not see usable signals in the gaps
- Sensor is not fully efficient at 15 mV threshold
- Worth studying 30-40 μm thick BNL sensors in the future?



HPK sensor thickness variations

- Results for HPK sensors that are 20, 30, and 50 µm thick
- 500x500 μm² channel size

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- Observe great timing performance
 - \sim 20 ps for 20 μ m thick sensor
 - ~25 ps for 30 µm thick sensor



HPK 20 micron results

- Can not use signal sharing for position reconstruction
- Do not have 2 pixel efficiency outside of the small non-metallized gaps
- Almost fully metallized
- Optimized for timing performance
 - Higher resistivity



HPK 20 micron results

- Enough signal sharing to cover gap fully
 - Not enough for position reconstruction
- Observe uniform time resolution across full sensor area





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Preliminary Conclusion

- New batch of BNL sensors have greatly improved gain uniformity
- Observe similar performance to previous batch for the 50 μ m thick sensors
- 100 to 50 µm
- BNL 20 µm thick sensors have small signal size
 - Adapt design, e.g. deeper gain layer, larger metal electrode, tune resistivity,...
 - Worth considering 30-40 µm thick sensors?
- HPK 20 and 30 µm sensors reach below 25 ps time resolution
 - Signal sharing not useful for position reconstruction
 - Fully efficient and have uniform time resolution
- Shown preliminary results and will continue analyzing the data

Small improvement to two strip efficiency observed when decreasing metal electrode size from









Sensors Tested

- 8 BNL sensors
 - 1 cm size, 50/100 µm width metal electrodes
 - 20 μm vs 50 μm
 - 2 wafer types
- 6 HPK 500x500µm pad E600, 2x2 sensors
 - 20 μ m (2 copies), 30 μ m (2 copies) and 50 μ m (2 copies thickness
 - Copies of the same sensor tested on FNAL and UCSC boards

	Thickness	Production	Channel Size	Gap	Wafe
5)	20 micron	BNL Strips	500 µm x 1.0 cm	400 µm	V
			500 µm x 1.0 cm	400 µm	V
			500 µm x 1.0 cm	450 μm	V
			500 µm x 1.0 cm	450 μm	V
		HPK Pixels	500x500 μm²	20-50 µm	
	30 micron	HPK Pixels	500x500 μm²	20-50 µm	
	50 micron	BNL Strips	500 µm x 1.0 cm	400 µm	N
			500 µm x 1.0 cm	450 μm	١
			500 µm x 1.0 cm	450 μm	N
			500 µm x 2.5 cm	400/450 µm mix	N
		HPK Pixels	500x500 μm²	20-50 µm	







Test beam 2021 results: HPK Pixels

- We have sensors from KEK and U. of Tsukuba that are fabricated at HPK
- Here we have a 2x2 pad sensor with 500 μ m size pads
- The overall performance we observe is great:
- Show effects of signal sharing in 2 dimensions by looking at the signal size for hits to the top left pad



HPK 2x2, 500 µm pad size

- 100% efficient, primary signal size are large (~128 mV), and signal sharing extends well into neighboring channel

